

# NEWS RELEASE

**Hitachi High-Tech**

**HITACHI**

**Hitachi High-Technologies Corporation**

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## **Notice of Patent Infringement Lawsuit against FEI Japan**

On September 22, 2010, Hitachi High-Technologies (Tokyo: 8036, Hitachi High-Tech) filed suit in the Tokyo District Court to request the payment of damages related to the infringement by FEI Japan of focused ion beam technology patents held by Hitachi High-Tech. This latest suit involves separate patent rights than those highlighted on July 29, 2010, when the Company previously filed suit against FEI Japan for damages related to patent infringement. \*

Hitachi High-Tech also filed for an injunction in the Tokyo District Court on November 6, 2009 to halt further patent infringement. \*\* This injunction is currently under litigation.

\*Notice of Patent Infringement Lawsuit against FEI Japan

(News release on July 30, 2010)

<http://www.hitachi-hitec.com/global/whatsnew/2010/nr20100730.pdf>

\*\*Notice of Patent Infringement Lawsuit against FEI Japan

(News release on November 6, 2009)

[http://www.hitachi-hitec.com/global/whatsnew/2009/20091106\\_2.pdf](http://www.hitachi-hitec.com/global/whatsnew/2009/20091106_2.pdf)

### Reference

Notice Regarding Injunction against the Import of FIB/SEM Equipment from FEI Company

(News release on June 30, 2010)

<http://www.hitachi-hitec.com/global/whatsnew/2010/nr20100630.pdf>

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